AMEND MENT

J.C. PATENTS

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# **FAX TRANSMISSION SHEET**

January 15, 2004

Our Ref

MART4591-R 09/759,899

Appl. No. : Filing Date :

January 12, 2001

Pages

Cover + 6

### BY FACSIMILE ONLY

FAX

703-308-6778

ATTN

Mr. George Allen

United States Patent and Trademark Office

FROM

Jiawei Huang, Reg. No.: 43,330

**MESSAGE:** 

Enclosed herewith is copy of the amendment filed on 03/11/2003.

Sir:

I hereby certify that this correspondence is being facsimile transmitted to the Patent and Trademark Office on <u>January 15, 2004</u> at the above indicated fax number.

Sign by:

Michelle Chang

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Atty Docket No.: MART4591 Serial No.: 09/759,899

# IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Application No.

: 09/759,899

Filed

: January 12, 2001

For

: TREATMENT ON SILICON OXYGNITRIDE

Applicant

: I. T. Chen

Examiner

: Ahmed, Shamim

Art Unit

: 1765

No fee is believed to be due. However, the Commissioner is authorized to charge any fees required in connection with the filing of this paper to account No. 50-0710 (Order No. MART4591).

# AMENDMENT AND RESPONSE TO OFFICE ACTION

#### **BOX Non-Fee Amendment**

Assistant Commissioner of Patents and Trademarks Washington, DC 20231

Dear Sir:

The Office Action mailed on December 12, 2002 has been carefully considered. In response thereto, please enter the following amendments and consider the following remarks.

### In The Title:

Please substitute the following clean copy title for the pending title:

--METHOD TO REMOVE SILICON OXIDE MATERIAL GENERATED DURING REMOVAL OF PHOTORESIST--